TAAB Filmed/Coated Grids

Formvar Support Films

Quantity	Copper Grid				
	100 mesh	200 mesh	300 mesh	400 mesh	
25	F231/025	F218/025	F232/025	F233/025	
50	F231/050	F218/050	F232/050	F233/050	
100	F231/100	F218/100	F232/100	F233/100	
	Nickel Grid				
25	F231/N025	F218/N025	F232/N025	F233/N025	
50	F231/N050	F218/N050	F232/N050	F233/N050	
100	F231/N100	F218/N100	F232/N100	F233/N100	
Gold Grid					
25	F231/G025	F218/G025	F232/G025	F233/G025	
50	F231/G050	F218/G050	F232/G050	F233/G050	

TAAB can offer high quality support films of formvar, formvar/carbon or pure carbon on a wide range of grid styles and makes depending on customer choice.

TAAB **carbon** films are limited to a maximum mesh size of 200 as our experience indicates that larger mesh sizes overstress the carbon and result in splits, tears or other problems either in manufacture, transit or the EM.

Plain **formvar** or **formvar/carbon** can be placed on most types of grid. Please ask for quotation if not listed.

Formvar/Carbon Support Films

Quantity	Copper Grid					
	100 mesh	100Hex	200 mesh	300 mesh	400 mesh	2 x 1mm
25	F200/025	F180/025	F077/025	F196/025	F098/025	F144/025
50	F200/050	F180/050	F077/050	F196/050	F098/050	F144/050
100	F200/100	F180/100	F077/100	F196/100	F098/100	F144/100
	Nickel Grid					
25	F200/N025	F180/N025	F077/N025	F196/N025	F098/N025	F144/N025
50	F200/N050	F180/N050	F077/N050	F196/N050	F098/N050	F144/N050
100	F200/N100	F180/N100	F077/N100	F196/N100	F098/N100	F144/N100
Gold Grid						
25	F200/G025	F180/G025	F077/G025	F196/G025	F098/G025	F144/G025
50	F200/G050	F180/G050	F077/G050	F196/G050	F098/G050	F144/G050



Quantity	y Copper Grid					
ĺ	100 mesh	100 Hex	200 mesh	300 mesh	400 mesh	2 x 1mm
1	_	_	C101/001	C267/001	C169/001	_
25	_	_	C101/025	C267/025	C169/025	_
50	_	_	C101/050	C267/050	C169/050	_
100	-	_	C101/100	C267/100	C169/100	_
Nickel Grid						
1	-	-	C101/N001	C267/N001	C169/N001	_
25	-	-	C101/N025	C267/N025	C169/N025	_
50	-	-	C101/N050	C267/N050	C169/N050	_
100	-	-	C101/N100	C267/N100	C169/N100	_
Gold Grid						
1	-	-	C101/G001	C267/G001	C169/G001	_
25	-	-	C101/G025	C267/G025	C169/G025	_
50	_	_	C101/G050	C267/G050	C169/G050	_

Carbon Support Films



Standard carbon films are ~ 17-20nm thick but 30nm is available on request

For optically flat, mechanically and solvent resistant electron transparent specimen supports, see our Silicon Nitride Windows page 1.27

Also see Quantifoil or C-Flat Ultra Flat Carbon Grids

Grids & Specimen Supports

Nitro-Cellulose/Carbon

Mounted	I on 200 mesh 3.05mm copper grids	
N056	Nitro-cellulose/Carbon film on 200 mesh cu grid	25
N056/1	Nitro-cellulose/Carbon film on 200 mesh cu grid	100

Silicon Monoxide

Mounted on 400 mesh 3.05mm copper grids

For certain applications silicon monoxide offers an exceptionally clean film and being carbon free, is valuable in some microanalysis investigations

50

S531 Silicon monoxide film on 400 mesh cu grid

Film Making Materials

POWDERS

F004 F005 An alterr Ultramic B026	Formvar Formvar native support film material to Formvar is Butvar B98 as repo rotomy 4,479 (1979). Exhibits good mechanical and high ele Butvar B98	100g 25g orted by Handley and Olsen, cctron beam stability. 100g
C282	Collodion	25g
SOLUT	TIONS	
F145/02	5 Formvar in chloroform 0.25%	100ml
F145/05	0 Formvar in chloroform 1%	100ml
F145/HA	Z Formvar in chloroform****	4 x 25ml
F244/02	5 Formvar in ethylene dichloride 0.25%	100ml
F244/05 F244/10	 Pormvar in ethylene dichloride 0.50% Formvar in ethylene dichloride 1% 	100ml 100ml
F244/HA	Z Formvar in ethylene dichloride****	4 x 25ml
C171/02	5 Collodion in amyl acetate 0.25%	100ml
C171/05	0 Collodion in amyl acetate 0.50%	100ml
C171/100 Collodion in amyl acetate 1% 100ml		
C171/200 Collodion in amyl acetate 2% 100ml		
C171/HAZ Collodion in amyl acetate **** 4 x 25ml		

Other strengths of solution can be made to order, please enquire.

**** Any of the above solutions can be packed in 25ml bottles 4 to a pack to avoid its classification as a hazardous chemical for shipping purposes. Please quote the relevant catalogue number and specify when ordering the strength of solution required.





Graphene and Graphene Oxide Coated Grids

There are currently two Graphene substrates available - **CVD Graphene** (chemical vapour deposition) and **Graphene Oxide** (GO). Graphene oxide films are typically laid down on lacey carbon films in suspension form with micrometer sized flakes with a less controlled thickness and evenness of coverage over the grid. CVD Graphene oxide films on the other hand are produced by oxidizing CVD Graphene films at relatively low temperatures in oxygen (typically 200°C or less). These are continuous films and typically have well characterized hydrophilic properties which is important for wetting the surface of the Graphene oxide film. This property aids in the dispersion of nano particles for example but is also important for cellular biology and protein chemistry applications. *GO films are considerably less costly than CVD Graphene.*

Graphene Oxide (GO) Support Films

Graphene oxide (GO) provides a support film up to 50% thinner than the equivalent carbon support but has a higher mechanical strength, electrical and thermal conductivity. TAAB Graphene Oxide support films are almost transparent in the electron beam and are available on holey and lacey carbon and Quantifoil® supports. These new GO films are hydrophilic and ideally suited to imaging of small nanoparticles, nanowires and suspensions. Their low atomic number and thin-layer thickness result in significantly lower background contrast than conventional supports. GO support films are also ideal for Cryo TEM studies. The vitreous ice layer can be significantly thinner on GO support films providing higher contrast and hence higher resolution for structural determination.



Graphene offers some unique advantages for studying interactions and processes at the atomic level. As the first readily available two-dimensional material, it is a model system for transmission electron microscopy studies; being almost electron transparent

it enables other species to be resolved on its surface with atomic resolution. It is also a well-defined surface, allowing surface science techniques to be integrated with high resolution transmission electron microscopy and scanning probe microscopy.

G203/10 GO film on *lacey* carbon on 300 mesh Hex Cu grid (10) **G203/50** GO film on *lacey* carbon on 300 mesh Hex Cu grid (50)

G217/10 GO film on *holey* carbon on 300 mesh Hex Cu grid (10) **G2127/50** GO film on *holey* carbon on 300 mesh Hex Cu grid (50)

G204/10 GO film on Quantifoil R 2/4 on 300 mesh Cu (10) **G204/50** GO film on Quantifoil R 2/4 on 300 mesh Cu (50)

 G219/10
 GO film on Quantifoil R 2/4 on 200 mesh Cu (10)

 G219/50
 GO film on Quantifoil R 2/4 on 200 mesh Cu (50)

G220/10 GO film on Quantifoil R 1.2/1.3 on 400 mesh Cu (10) **G220/50** GO film on Quantifoil R 1.2/1.3 on 400 mesh Cu (50) G203/25 GO film on *lacey* carbon on 300 mesh Hex Cu grid (25)

G217/25 GO film on holey carbon on 300 mesh Hex Cu grid (25)

G204/25 GO film on Quantifoil R 2/4 on 300 mesh Cu (25)

G219/25 GO film on Quantifoil R 2/4 on 200 mesh Cu (25)

G220/25 GO film on Quantifoil R 1.2/1.3 on 400 mesh Cu (25) Available on other supports to special order

Graphene TEM Support Films

Our Graphene TEM support films are supported by a lacey carbon film on a 300 mesh copper grid. The single, continuous Graphene sheet covers the entire 300 mesh area of the TEM grid. This creates a usable area of around 75% of the TEM grid, leaving plenty of space for specimens or experiments. The Graphene films are available with either 1, 2, 3-5 or 6-8 layers of Graphene. The 2 layer Graphene is ideally suited for high resolution TEM imaging, imaging of nanoparticles and imaging of weak contrast materials. Graphene exhibits excellent conductivity and very high transparency for electrons. The more robust 3-5 and 6-8 layer Graphene are offered for use as an experimental platform for Graphene research. It can be used for nano scale experiments or Graphene applications research with subsequent high resolution imaging.

The Graphene used for these Graphene TEM support films is grown on copper foil using a CVD process. The Graphene is then released by dissolving the copper foil and transferred onto the lacey carbon/300mesh grid by using a proprietary transfer technique.

Continued over page



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Grids & Specimen Supports

Graphene Films on Grids

All films are on lacey carbon 300 mesh copper grids. Available in packs of 5, 10 or 29					
in grid box.					
G205/5	Single layer Graphene on 300 mesh lacey carbon pack of 5				
G20510	Single layer Graphene on 300 mesh lacey carbon pack of 10				
G205/25	Single layer Graphene on 300 mesh lacey carbon pack of 25				



3-5 layer Graphene on Lacey Carbon film. Marker bar = 5μ m

Graphene Films on Holey Silicon Nitride



G212/25

Holey Silicon Nitride Support

Graphene Films on Ultra-flat SiO₂ Substrate



2 Layer Graphene Support Films

Single Layer Graphene Support Films

G206/5	Two layer Graphene on 300 mesh lacey carbon pack of 5
G206/10	Two layer Graphene on 300 mesh lacey carbon pack of 10
G206/25	Two layer Graphene on 300 mesh lacey carbon pack of 25

3 to 5 Layer Graphene Support Films

G207/5	3-5 layer Graphene on 300 mesh lacey carbon pack of 5
G207/10	3-5 layer Graphene on 300 mesh lacey carbon pack of 10
G207/25	3-5 layer Graphene on 300 mesh lacey carbon pack of 25

6 to 8 Layer Graphene Support Films

G208/5	6-8 layer Graphene on 300 mesh lacey carbon pack of 5
G208/10	6-8 layer Graphene on 300 mesh lacey carbon pack of 10
G208/25	6-8 layer Graphene on 300 mesh lacey carbon pack of 25

Graphene supported by Holey Silicon Nitride which has 2.5µm holes with a 4.5µm pitch in 200nm Si3N4 over a 0.5 x 0.5mm window size. The Graphene sheet covers the complete window with the ultraflat Si3N4 holey membrane and leaves free standing Graphene covering the 2.5µm holes. Total usable area is approx. 75% due to unavoidable folds and wrinkles in the Graphene sheet. Available with single, 2, 3-5, and 6-8 layer Graphene sheets. Research-ready product, suitable for UHR imaging or as ultra-flat experimental platform. Graphene specification as for above 300 mesh lacey carbon.

Single Laver Graphene on Holey Silicon Nitride as above pack of 5
Single Layer Graphene on Holey Silicon Nitride as above pack of 10
Single Layer Graphene on Holey Silicon Nitride as above pack of 25
2 layer Graphene on Holey Silicon Nitride as above pack of 5
2 layer Graphene on Holey Silicon Nitride as above pack of 10
2 layer Graphene on Holey Silicon Nitride as above pack of 25
3-5 layer Graphene on Holey Silicon Nitride as above pack of 5
3-5 layer Graphene on Holey Silicon Nitride as above pack of 10
3-5 layer Graphene on Holey Silicon Nitride as above pack of 25
6-8 layer Graphene on Holey Silicon Nitride as above pack of 5
6-8 layer Graphene on Holey Silicon Nitride as above pack of 10
6-8 layer Graphene on Holey Silicon Nitride as above pack of 25

Graphene on Ultra-flat SiO₂ substrate offered for use as a research-ready experimental platform. The Graphene sheet covers the complete 5 x 5mm diced substrate. Total usable area is approx. 75% due to unavoidable folds and wrinkles in the Graphene sheet. Suitable for AFM imaging or as ultra-flat experimental platform. The Specification of the Graphene is the same as mentioned above. Supplied in a Gel-Pak box and packed in class 10 clean room conditions. Consists of a 200nm thermally grown SiO₂ film on an ultra-flat silicon wafer with a normal thickness of 675 μ m.

G213/5Single Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 5G213/10Single Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 10G213/25Single Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 25G214/52 Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 5G214/102 Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 5G214/102 Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 10G214/252 Layer Graphene on Ultra-flat Thermal SiO2 Substrate, 5x5mm pack of 10G214/253-5 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 5G215/103-5 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 10G215/253-5 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 25G216/56-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 5G216/106-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 5G216/266-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 5G216/266-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 25G216/266-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 10G216/266-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 10G216/266-8 Layer Graphene on Ultra-flat Thermal SiO2 Substrate 5x5mm pack of 25



Grids & Specimen Supports

20 sheets

20 sheets

20 sheets

20 sheets

3 sheets

pack of 10

10 sheets

50

50

50

50

50

50

1

Mica Sheets

High grade mica for making freshly cleaved surfaces for such EM applications as carbon filming and particle spraying. Also suitable for high reolution AFM studies, growing cells and thin film coating research.

Available in the following sizes as stock items, other sizes can be supplied please enquire.

- M054
 Mica 3" x 1" x 0.006" thick (75 x 25 x 0.15mm)

 M055
 Mica 1" x 1" x 0.006" thick (25 x 25 x 0.15mm)
- M459 Mica 11 x 11 x 0.15mm thick
- M460 Mica 100 x 20 x 0.15mm thick
- M461 Mica 150 x 150 0.15mm thick
- M462 Mica 9.9mm dia x 0.1mm thick
- M463 Mica 20 x 20mm thick ultra clean

Lacey Carbon Films

These are carbon films with large holes, which make them particularly suitable for the support of acicular crystals. Much of the crystal is unsupported and therefore subject to a minimum of incoherent scattering from the film. **C269/C** Lacey carbon film 300 mesh, 3.05mm, Cu 50

C269/C Lacey carbon filr	n 300 mesh, 3.05mm, Cu
C269/N Lacey carbon filr	n 300 mesh, 3.05mm, Ni
C270/C Lacey carbon filr	n 400 mesh, 3.05mm, Cu
C270/N Lacey carbon filr	n 400 mesh, 3.05mm, Ni
C270/G Lacev carbon f	ilm 400 mesh. 3.05mm.Au

Holey Carbon Films

These are similar to lacey carbon films with smaller holes. **C062/C** Holey carbon film 300 mesh, 3.05mm, Cu **C062/N** Holey carbon film 300 mesh, 3.05mm, Ni **C062/G** Holey carbon film 300 mesh, 3.05mm, Au **C274/C** Holey carbon film 400 mesh, 3.05mm, Cu **C274/N** Holey carbon film 400 mesh, 3.05mm, Ni **C274/G** Holey carbon film 400 mesh, 3.05mm, Au

Grid Coating Pen

The Grid Coating pen improves the adherence of tissue sections onto the grids. With a touch of the pen to the grid, a thin layer of coating is applied to the grid. Drying takes place in 1-2 minutes at room temperature. After it has dried the grid is ready for section mounting. The pen can also be used in pretreating grids prior to mounting support films such as formvar and carbon. This minimises dislodging, widening or breaking of the support film.

P293 Grid Coating Pen

Grid Coating Stand

A stand designed with 49 recessed holes suitable for 3.05mm diameter grids. A groove is carefully machined to the correct depth which allows safe and easy access for tweezer manipulation of the grids.

Standing on 3 integral feet it is easily placed in a low glass dish to allow thin collodion or formvar films to be lowered onto the grids by siphoning off the water. The coated grids can then be transferred to the coating unit.

Fax: +44 (0) 118 981 7881 E-mail: sales@taab.co.uk

G122 Grid coating stand, thin film

Phone: +44 (0) 118 981 7775











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